

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Kiyoshi ARAKAWA) : Prior Examiner: H. Nguyen
Application No.: Continuation of Application) : Prior Group Art Unit: 2851
No. 09/986,918, filed November 13, 2001)
Filed: July 14, 2003)
For: EXPOSURE APPARATUS, MAINTENANCE)
METHOD THEREFOR, SEMICONDUCTOR) : July 18, 2003
DEVICE MANUFACTURING METHOD :
USING THE APPARATUS, AND)
SEMICONDUCTOR MANUFACTURING)
FACTORY)

Mail Stop Patent Application

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT

Sir:

Prior to examination on the merits, please amend the above-identified application as follows:

INTRODUCTORY COMMENTS

This Amendment has been prepared in accordance with the Revised Format established by the U.S. Patent and Trademark Office, as permitted in the Pre-OG Notice dated February 4, 2003, and entitled "Amendments in a Revised Format Now Permitted."